



**UNITED STATES DEPARTMENT OF COMMERCE**  
**Pat nt and Trademark Office**

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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.
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09/109,261 06/30/98 BAI

G 042390.P5769

EXAMINER

MMC2/0131

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WARREN, M

ART UNIT

PAPER NUMBER

2815

DATE MAILED:

01/31/01

**Please find below and/or attached an Office communication concerning this application or proceeding.**

**Commissioner of Patents and Trademarks**

<p style="text-align: center;"><b>Office Action Summary</b></p>	Application No. 09/109,261	Applicant(s) Bai	
	Examiner Matthew E. Warren	Art Unit 2815	

-- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --

**Period for Reply**

A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION.

- Extensions of time may be available under the provisions of 37 CFR 1.136 (a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.
- If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely.
- If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.
- Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133).
- Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).

**Status**

- 1) ☒ Responsive to communication(s) filed on 26 December 2000.
- 2a) ☐ This action is FINAL.                      2b) ☒ This action is non-final.
- 3) ☐ Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under *Ex parte Quayle*, 1935 C.D. 11, 453 O.G. 213.

**Disposition of Claims**

- 4) ☒ Claim(s) 8-21 is/are pending in the application.
- 4a) Of the above claim(s) \_\_\_\_\_ is/are withdrawn from consideration.
- 5) ☐ Claim(s) \_\_\_\_\_ is/are allowed.
- 6) ☒ Claim(s) 8-21 is/are rejected.
- 7) ☐ Claim(s) \_\_\_\_\_ is/are objected to.
- 8) ☐ Claims \_\_\_\_\_ are subject to restriction and/or election requirement.

**Application Papers**

- 9) ☐ The specification is objected to by the Examiner.
- 10) ☐ The drawing(s) filed on \_\_\_\_\_ is/are objected to by the Examiner.
- 11) ☐ The proposed drawing correction filed on \_\_\_\_\_ is: a) ☐ approved b) ☐ disapproved.
- 12) ☐ The oath or declaration is objected to by the Examiner.

**Priority under 35 U.S.C. § 119**

- 13) ☐ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d).
- a) ☐ All b) ☐ Some \* c) ☐ None of:
1. ☐ Certified copies of the priority documents have been received.
  2. ☐ Certified copies of the priority documents have been received in Application No. \_\_\_\_\_.
  3. ☐ Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).
- \* See the attached detailed Office action for a list of the certified copies not received.
- 14) ☐ Acknowledgement is made of a claim for domestic priority under 35 U.S.C. & 119(e).

**Attachment(s)**

- |   |  |
|---|--|
| 15) <input checked="" type="checkbox"/> Notice of References Cited (PTO-892)                  | 18) <input type="checkbox"/> Interview Summary (PTO-413) Paper No(s). _____  |
| 16) <input type="checkbox"/> Notice of Draftsperson's Patent Drawing Review (PTO-948)         | 19) <input type="checkbox"/> Notice of Informal Patent Application (PTO-152) |
| 17) <input type="checkbox"/> Information Disclosure Statement(s) (PTO-1449) Paper No(s) _____ | 20) <input type="checkbox"/> Other: _____                                    |

### DETAILED ACTION

This Office Action is in response to the CPA and Preliminary Amendment filed on December 26, 2000.

#### ***Claim Rejections - 35 USC § 103***

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negated by the manner in which the invention was made.

Claims 8-13, and 15-20 are rejected under 35 U.S.C. 103(a) as being unpatentable over Gardner et al. (US 5,963,810) in view of Nagata et al. (US 4,015,281) and Momose et al. (US 5,990,516).

Gardner shows (fig. 3D) a semiconductor device having a multi-layered gate dielectric formed directly on the substrate. The first dielectric layer (303) of the gate dielectric is formed on the substrate. The first dielectric layer is silicon nitride (col. 5, lines 25-44). The second dielectric layer of the gate dielectric is a high dielectric constant material (305) of BST (col. 3, lines 15-43) and is formed on the first dielectric layer. The dielectric constant of the first dielectric layer (SiN) is less than the dielectric constant of the second dielectric layer (BST). A gate electrode (307a) is formed on the multi-layered gate dielectric. Gardner shows all of the elements of the claims except the for the formula to determine the dielectric constant and the thickness of the dielectric being less than 1/3 the gate length. Nagata discloses in column 4, starting at line 40,

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an expanded formula to determine the dielectric constant. Momose et al. discloses (col. 2, lines 52-58) a semiconductor device in which the gate dielectric is less than  $1/3$  the gate length. The thin gate dielectric improves hot carrier reliability and ultimately the operating characteristics. Therefore it would have been obvious to one of ordinary skill in the art at the time the invention was made to modify the gate dielectric of Gardner by using the formula disclosed by Nagata to determine the appropriate thickness of a bi-layered gate dielectric. It would have been obvious to also modify the gate dielectric of Gardner by providing the dielectric with a thickness in relation to the gate length. Momose teaches that determining the thickness of the gate dielectric with respect to the gate length helps improve operational characteristics.

Claims 14 and 21 are rejected under 35 U.S.C. 103(a) as being unpatentable over Gardner et al. (US 5,963,810) in view of Nagata et al. (US 4,015,281) and Momose et al. (US 5,990,516) as applied to claims 8 and 15 above, and further in view of Sato (US 5,258,645).

Gardner shows all of the elements of the claims except the third dielectric layer having a third dielectric constant. Sato discloses (col. 6, lines 49-58) a semiconductor device having a third insulating layer (12) formed as part of a tri-layered gate dielectric (17). The third layer (12) is silicon oxide and has a different dielectric constant than SiN and BST. The three layer gate dielectric is formed to optimize the threshold voltage of the device and ultimately improve device characteristics (col. 4, lines 17-21). Therefore it would have been obvious to one of ordinary skill in the art to modify the bi-layer gate

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dielectric of Gardner by adding a third layer of dielectric material because Sata teaches that a triple layered gate dielectric optimizes the threshold voltage of a semiconductor and ultimately improves the device characteristics.

### ***Response to Arguments***

Applicant's arguments with respect to claims 8-21 have been considered but are moot in view of the new ground(s) of rejection.

### ***Conclusion***

The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. Takata (US 5,355,011) also shows a gate dielectric whose thickness is less than 1/3 the gate length.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Matthew E. Warren whose telephone number is (703) 305-0760. The examiner can normally be reached on Mon-Thurs, and alternating Fri, 9:00-5:00.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Eddie Lee can be reached on (703) 308-1690. The fax phone numbers for the organization where this application or proceeding is assigned are (703) 305-3432 for regular communications and (703) 308-7722 for After Final communications.

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Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) 308-0956.

MEW

*MEW*  
January 26, 2001



**EDDIE C. LEE**  
**PRIMARY EXAMINER**